Scalable and sustainable production of Ti$_3$C$_2$T$_z$ MXene and fluorine recovery from wastewater through cryolite precipitation

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Introduction

Traditional synthesis of Ti$_3$C$_2$T$_z$ MXene, most commonly obtained by the selective etching of Al from a Ti$_3$AlC$_2$ MAX phase with hydrofluoric acid, HF, requires a large amount of water to obtain a colloidal suspension of few, to single, flake Ti$_3$C$_2$T$_z$ suspensions. Typically, the amount of water needed is at least 640 mL per gram of MXene as this water is thought to both wash away residual salts formed in the etching process, and to bring the solution pH to neutral at which point a stable colloidal MXene suspension forms. Herein we show that by modifications made to the synthesis process, we can obtain Ti$_3$C$_2$T$_z$ colloidal suspensions with 75% less water utilized in the washing procedure. The fluorine, F, in the remaining wastewater can also be recovered through the precipitation of cryolite.

While MXenes have been shown to be quite promising in terms of their performance across a wide variety of applications, their widescale production has lagged. One of the limiting steps at this time is the large cost of their production and the need for F in the etching medium. Additionally, the treatment of HF containing wastewater is both a major industrial and environmental concern.*

For MXene production to occur at industrial scales, the large amount of acidic wastewater that is currently a byproduct of its methods of production must be addressed. Furthermore, the presence of F$^-$ in this wastewater is problematic as this treatment is quite costly and produces a large amount of industrial waste sludge that becomes difficult to dispose of due to environmental regulations.* It was long believed that the main product of the selective etching of Al from Ti$_3$AlC$_2$ to yield Ti$_3$C$_2$T$_z$ is AlF$_3$, which has limited solubility in water (0.5 g/100 g H$_2$O at 25 °C). However, Cockreham et al. showed that AlF$_3$ formation only occurs under a range of ionic strength from 8.5 to 10 M and other aluminum/fluorine complex ions are dominant outside this range. If H$_2$AlF$_6$ is present, then a route to recovering F from the wastewater exists through the addition of sodium cations to form sodium hexafluoroaluminate, otherwise known as cryolite, which can be readily isolated from the spent etching liquid. The yield of precipitated cryolite allows for the calculation of Al etching efficiency, while also being a product of commercial value. In the reaction of the Al in Ti$_3$AlC$_2$ with HF, a route for the formation of hexafluoroaluminate acid and cryolite may be as follows:

$$2\text{Al} + 6\text{HF(aq)} \rightarrow 2\text{AlF}_3(\text{aq}) + 3\text{H}_2(\text{g}) \quad (1)$$

$$\text{AlF}_3(\text{aq}) + 3\text{HF} \rightarrow \text{H}_2\text{AlF}_6(\text{aq}) \quad (2)$$

$$2\text{H}_3\text{AlF}_6(\text{aq}) + 3\text{Na}_2\text{CO}_3 \rightarrow 2\text{Na}_3\text{AlF}_6 + 3\text{H}_2\text{O} + 3\text{CO}_2(\text{g}) \quad (3)$$

With the typical etching procedures using HF or HCl/LiF there is enough HF to fully convert AlF$_3$ to H$_2$AlF$_6$. Furthermore, AlF$_6^{3-}$ is believed to be a stable species as the ionic strength of the solution increases. In this reaction, the formation of...
H$_3$AlF$_6$ may provide a driving force for the continued extraction of Al from Ti$_3$AlC$_2$, potentially explaining why HF is the only acid capable of etching the MAX phase to yield MXenes.$^5$,$^1^8$ The structures of hexafluoroaluminic acid and cryolite are shown in Fig. 1.

Sodium hexafluoroaluminate, Na$_3$AlF$_6$, more commonly known as cryolite, is insoluble in water, but soluble in sulfuric acid, H$_2$SO$_4$, with the evolution of HF. Synthetic cryolite finds widespread industrial use as a flux agent to dissolve alumina, Al$_2$O$_3$, in the electrolytic metal extraction process. It is also consumed in the abrasives, ceramic and glass industries.$^{15}$,$^{19}$ Many research articles and patents have appeared over the years regarding the production of cryolite, suggesting that if cryolite can be isolated and repackaged as a by-product of MXene production, the economics associated with the scale-up of MXene synthesis may be partially offset. By our calculations, assuming complete etching of Al from Ti$_3$AlC$_2$ and complete conversion to cryolite, 1.07 g may be produced from 1 g of Ti$_3$AlC$_2$. This may be an attractive method to lower the cost of conversion to cryolite, 1.07 g may be produced from 1 g of Ti$_3$AlC$_2$. This may be an attractive method to lower the cost of wastewater treatment and produce a high purity, high value compound, while also providing a quantitative tool for the determination of etching efficiency. The feasibility of this method is supported by the work of Kumar et al. which showed that the recovery of synthetic cryolite from the treatment of synthetic HCl/HF leach liquors comprising H$_3$SiF$_6$ and H$_3$AlF$_6$ with 3 M Na$_2$CO$_3$ was 97.5%.$^{15}$

In this work we demonstrate that by washing the acidified MXene sediment once with a mild solution of low-cost and environmentally benign sodium bicarbonate, BC, colloidal suspensions can be produced using 75% less deionized water than otherwise needed. This reduction in wastewater is achieved independent of the etching method (HF vs. HCl/LiF). By similarly treating the waste HF etching liquid with 3 M sodium carbonate, cryolite can easily be formed and precipitated, according to reaction (3), providing a useful method for the determination of Al extraction efficiency as well as providing a value-added product which effectively removes F from the waste stream.

**Results & discussion**

The sediments produced by this method were first investigated by XRD to ensure that etching of the MAX phase was complete, and to characterize the obtained MXene. In Fig. 2, XRD patterns of multilayer (ML) MXene obtained by normal deionized (DI) water washing, with 8 washes of DI (middle, black), ML MXene after 1 wash with 40 mL 0.05 M NaHCO$_3$ and 2 washes of DI, (top, red) and the precipitated Na$_3$AlF$_6$ from the spent etching liquid. A reference profile for Na$_3$AlF$_6$ (dotted bottom red).

Fig. 1  (a) Structure of hexafluoroaluminic acid, and (b) structure of cryolite, Na$_3$AlF$_6$.

Fig. 2  XRD patterns of MXene obtained by normal washing 8 times with DI (black – solid line is HF etched ML, dotted line is HCl/LiF etched delaminated films), after 1 wash with 0.05 M NaHCO$_3$ and 2 times with DI (red – solid line is HF etched ML, dotted line represents HCl/LiF etched delaminated films), Ti$_3$AlC$_2$ MAX phase precursor (orange), the precipitated Na$_3$AlF$_6$ (blue), and a reference profile for Na$_3$AlF$_6$ (dotted bottom red).
with only DI H₂O. However after treatment with 0.05 M NaHCO₃ (regardless of HF or HCl/LiF etching method), this stability occurred within two rounds of washing, as seen in Fig. 3. Interestingly, a stable suspension is found after just the first wash (Fig. 3a). However in our washing procedure, an additional wash step was carried out that resulted in a darker, more concentrated suspension (Fig. 3b). Washing with DI H₂O only, required 640 mL. However with the incorporation of one 40 mL 0.05 M NaHCO₃ wash before subsequent DI washes, the volume of water necessary to produce a dark colloidal suspension was 160 mL per gram of Ti₃C₂Tₓ sediment. An SEM micrograph of the Ti₃C₂Tₓ filtered film after exposure to NaHCO₃ can be seen in Fig. 4a and b along with an SEM micrograph of the obtained Na₃AlF₆ in Fig. 4c.

Typically, Ti₃C₂Tₓ produced by etching with HF, only do not yield delaminated flakes (referred to as d-Ti₃C₂Tₓ, to insinuate delamination) without the use of a chemical exfoliation agent such as TBAOH or DMSO. However, with our approach, a colloidal suspension was obtained after NaHCO₃ and DI water washing, and a film of d-Ti₃C₂Tₓ was produced by vacuum filtration of this suspension (Fig. 4a). A photograph of this colloidal suspension, and the Tyndall effect produced by the d-Ti₃C₂Tₓ flakes, is shown as an inset of Fig. 4a. Conductivity measurements were conducted on this film with a four-point probe, and a DC conductivity of 180 ± 10 S cm⁻¹ was measured.

A film was attempted to be produced by the DMSO assisted intercalation and delamination of HF etched, water only washed, Ti₃C₂Tₓ, however the concentration of this suspension was so slow that a continuous film was unable to be obtained. Conductivity measurements were attempted on a section of this ‘film’ and a value of 2.25 ± 0.05 S cm⁻¹ was measured.

Conductivity measurements were similarly conducted on HCl/LiF etched films, one washed first with 0.05 M NaHCO₃, and the other washed only with water. In the BC washed case, the colloidal suspension had a concentration of 18 mg mL⁻¹ and a film produced from this suspension had conductivity of 1150 ± 27 S cm⁻¹ was measured, while the H₂O washed colloidal suspension had a concentration of 15.6 mg mL⁻¹ and the corresponding film had a conductivity of 1330 ± 54 S cm⁻¹.
These are comparable to the conductivity of Ti$_3$C$_2$T$_2$ clay reported by Ghidiu et al.²

**Conclusions**

In summary, a simple yet effective method of obtaining Ti$_3$C$_2$T$_2$ MXene is presented where the isolated etched sediment is neutralized with a mild solution of sodium bicarbonate. In so doing, the pH can directly be adjusted to neutral without the need of large volumes of DI water. This drastically reduces the amount of wastewater generated, specifically from 640 mL g$^{-1}$ to 160 mL g$^{-1}$, a reduction of 75%. This holds for both HF only and HCl/LiF etched Ti$_3$C$_2$T$_2$. Furthermore, when etched with HF, delaminated films of Ti$_3$C$_2$T$_2$ could be produced, provided they were treated with 0.05 M NaHCO$_3$ before washing with deionized water. Furthermore, films produced by etching with HCl/LiF and then washed once with 0.05 M NaHCO$_3$, followed by two washes with deionized water resulted in a colloidal suspension with a concentration of 18 mg mL$^{-1}$. These are comparable to the conductivity of Ti$_3$C$_2$T$_2$ ML sediment isolated from the etching liquid through centrifugation. The spent liquid portion is set aside and used for cryolite precipitation. After separation, the sediment in each centrieuge tube (0.5 g per tube) was treated with 40 mL of 0.05 M NaHCO$_3$ so that the pH was adjusted to 7.0. After the initial wash with 0.05 M NaHCO$_3$, the sediment was washed two times with 40 mL of DI water.

**Materials & methods**

The experimental approach in this work is largely separated into two segments which are focused on: (1) neutralization of the MXene sediment to obtain high quality Ti$_3$C$_2$T$_2$ MLs with less water, and (2) precipitation of cryolite from the spent etching waste.

Two etching methods are explored in this work. Namely, the use of HF acid only as well as the method first reported by Ghidiu et al. utilizing hydrochloric acid and lithium fluoride to produce HF in situ.² The latter method is more widely adopted due to the improved handling safety and ability to directly yield delaminated suspensions. However, when considering the precipitation of cryolite through neutralization of the spent etching liquid, the HF only method is a much cleaner system, as there are fewer ionic species present. For the purposes of this work, we demonstrate that cryolite, Na$_3$AlF$_6$, can be precipitated from the spent etching media obtained from the HF-only method.

The neutralization of the MXene sediment with 40 mL 0.05 M NaHCO$_3$ is applicable to both methods of MXene production. Given that the HCl/LiF method is more widely adopted by those that work with MXene, we felt it was important to demonstrate the effectiveness of this washing procedure when working with HCl/LiF etched MXene.

**HF etching of Ti$_3$AlC$_2$ to produce HF–Ti$_3$C$_2$T$_2$**

MXene etched by HF acid only, (henceforth referred to as HF–Ti$_3$C$_2$T$_2$) was obtained by etching 1 g of Ti$_3$AlC$_2$ MAX phase in 10 mL of 10% HF for 24 h at RT.

**Sodium bicarbonate washing of HF–Ti$_3$C$_2$T$_2$**

After the etching period, the HF–Ti$_3$C$_2$T$_2$ ML sediment is isolated from the etching liquid through centrifugation. The spent liquid portion is set aside and used for cryolite precipitation. After separation, the sediment in each centrifuge tube (0.5 g per tube) was treated with 40 mL of 0.05 M NaHCO$_3$ so that the pH was adjusted to 7.0. After the initial wash with 0.05 M NaHCO$_3$, the sediment was washed two times with 40 mL of DI water.

**Precipitation of cryolite from HF–Ti$_3$C$_2$T$_2$ etching media**

Cryolite was precipitated by adding 3 M Na$_2$CO$_3$ to the isolated etching liquid until a pH of 4.0. This solution was then kept in a 55 °C oil bath for 1 h, after which the gelatinous liquid was vacuum filtered over a Celgard polypropylene membrane where a white crystalline solid was formed.

**HCl/LiF-etched Ti$_3$C$_2$T$_2$**

To demonstrate the applicability of this method to the more widely used method first reported by Ghidiu et al.,² two grams of Ti$_3$C$_2$T$_2$ were prepared by etching two grams of Ti$_3$AlC$_2$ in 20 mL of 12 M HCl along with two grams of lithium fluoride. This mixture was allowed to mix at 35 °C for 48 h at 300 rpm.

After etching, the contents of the etching bottle were split equally into four centrifuge tubes so that 0.5 g of sediment was in each centrifuge tube. Two of the tubes were washed only with deionized water, while the other two were first washed with...
40 mL of 0.05 M NaHCO₃, followed by two washes with deionized water.

After the washing period, the contents of the tubes were combined so that roughly 1 g of each separately washed powders of Ti₃C₂T₁ were in each tube. 20 mL of DI H₂O was added to each tube, and these mixtures were bath sonicated for 1 h under flowing argon. After sonication, the colloidal suspensions were collected by centrifugation at 5000 rpm for 10 minutes. These colloidal suspensions were filtered into films by vacuum filtration.

**Author contributions**

M. C. conducted all experiments and wrote the manuscript along with M. W. B. who oversaw the project.

**Conflicts of interest**

There are no conflicts to declare.

**References**